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AMENDMENT TRANSMITTAL LETTER			Docket No. 0171-1100PUS1	
Application No. 10/849,186-Conf. #7245	Filing Date May 20, 2004	Examiner J. S. Y. Chu	Art Unit 1752	
Applicant(s): Takeru WATANABE et al.				
Invention: BASIC COMPOUND, RESIST COMPOSITION AND PATTERNING PROCESS				
MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450				
Transmitted herewith is an amendment in the above-identified application. The fee has been calculated and is transmitted as shown below.				
CLAIMS AS AMENDED				
	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate
Total Claims	9	- 20 =		x
Independent Claims	2	- 7 =		x
Multiple Dependent Claims (check if applicable) <input type="checkbox"/>				
Other fee (please specify):				
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT:				0.00
<input checked="" type="checkbox"/> Large Entity <input type="checkbox"/> Small Entity				
<input checked="" type="checkbox"/> No additional fee is required for this amendment.				
<input type="checkbox"/> Please charge Deposit Account No. _____ in the amount of \$ _____. A duplicate copy of this sheet is enclosed.				
<input type="checkbox"/> A check in the amount of \$ _____ to cover the filing fee is enclosed.				
<input type="checkbox"/> Payment by credit card. Form PTO-2038 is attached.				
<input checked="" type="checkbox"/> The Director is hereby authorized to charge and credit Deposit Account No. <u>02-2448</u> as described below. A duplicate copy of this sheet is enclosed.				
<input checked="" type="checkbox"/> Credit any overpayment.				
<input checked="" type="checkbox"/> Charge any additional filing or application processing fees required under 37 CFR 1.16 and 1.17.				
Gerald M. Murphy, Jr. Attorney Reg. No.: 28,977 BIRCH, STEWART, KOLASCH & BIRCH, LLP 8110 Gatehouse Road Suite 100 East P.O. Box 747 Falls Church, Virginia 22040-0747 (703) 205-8000			Dated: <u>December 15, 2005</u>	



Docket No.: 0171-1100PUS1
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Takeru WATANABE et al.

Application No.: 10/849,186

Confirmation No.: 7245

Filed: May 20, 2004

Art Unit: 1752

For: BASIC COMPOUND, RESIST COMPOSITION
AND PATTERNING PROCESS

Examiner: J. S. Y. Chu

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In reply to the outstanding Office Action dated September 26, 2005, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

This reply includes: An Amended Set of Claims; and
Remarks.